CLOTH WITH PATTERN

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Term: 14 Years

Appl. No.: 29/512,783

Filed: Dec. 23, 2014

Primary Examiner — Karen S Acker

The ornamental design for a cloth with pattern, as shown and described.

DESCRIPTION

The patent or application file contains at least one drawing executed in color. Copies of this patent or patent application publication with color drawing(s) will be provided by the Office upon request and payment of the necessary fee.

The sole FIGURE is a top plan view of a cloth with pattern. The cloth with pattern is shown with symbolic breaks in its length and width. The appearance of any portion of the article between the break lines forms no part of the claimed design. The broken lines form no part of the claimed design.

1 Claim, 1 Drawing Sheet

(1 of 1 Drawing Sheet(s) Filed in Color)